

## Fabrication of High-Power AlGa<sub>N</sub>/Ga<sub>N</sub> Schottky Barrier Diode with Field Plate Design

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**Abstract :** In this letter, we demonstrate high-performance AlGa<sub>N</sub>/Ga<sub>N</sub> planar Schottky barrier diodes (SBDs) on the silicon substrate with field plate structure for increasing breakdown voltage  $V_B$ . A low turn-on resistance  $R_{ON}$  ( $3.55 \text{ m}\Omega\text{-cm}^2$ ), low reverse leakage current ( $< 0.1 \mu\text{A}$ ) at  $-100 \text{ V}$ , and high reverse breakdown voltage  $V_B$  ( $> 1.1 \text{ kV}$ ) SBD has been fabricated. A virgin SBD exhibited a breakdown voltage (measured at  $1 \text{ mA/mm}$ ) of  $615 \text{ V}$ , and with the field plate technology device exhibited a breakdown voltage (measured at  $1 \text{ mA/mm}$ ) of  $1525 \text{ V}$  (the anode-cathode distance was  $L_{AC} = 40 \mu\text{m}$ ). Devices without the field plate design exhibit a Baliga's figure of merit of  $V_B^2 / R_{ON} = 60.2 \text{ MW/cm}^2$ , whereas devices with the field plate design show a Baliga's figure of merit of  $V_B^2 / R_{ON} = 340.9 \text{ MW/cm}^2$  (the anode-cathode distance was  $L_{AC} = 20 \mu\text{m}$ ).

**Keywords :** AlGa<sub>N</sub>/Ga<sub>N</sub> heterostructure, silicon substrate, Schottky barrier diode (SBD), high breakdown voltage, Baliga's figure-of-merit, field plate

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